

[54] FACIAL MASK

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[\*\*] Term: 14 Years

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[52] U.S. Cl. .... D2/234; D2/239

[58] Field of Search ..... D2/230, 234, 233, 239, D2/253; 2/206; 128/132 R, 136, 139; D24/49

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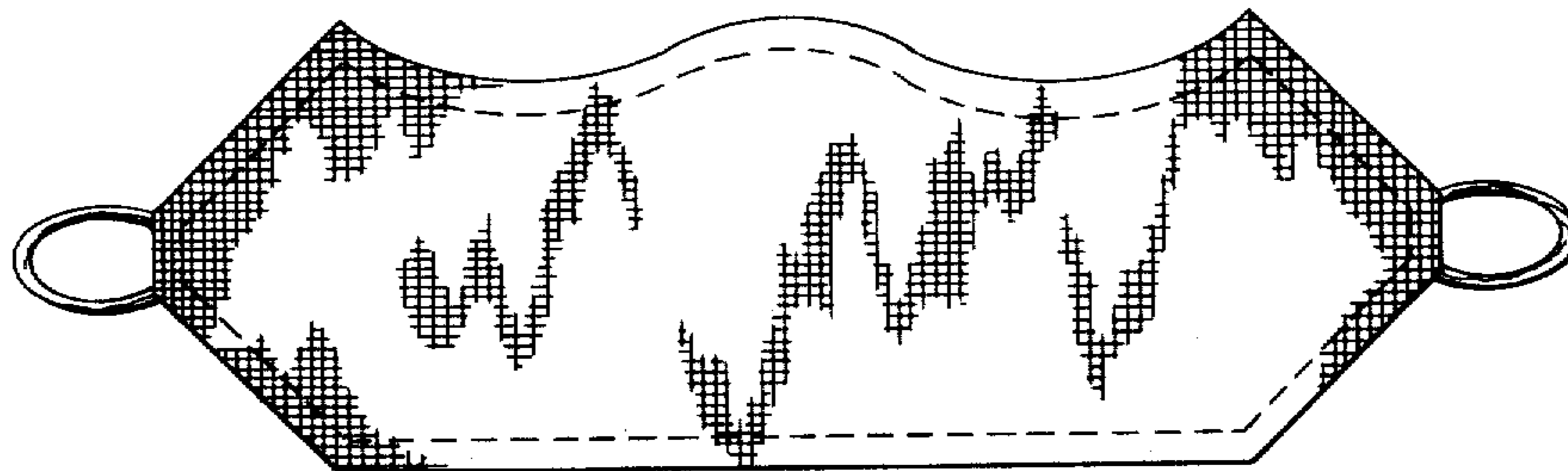
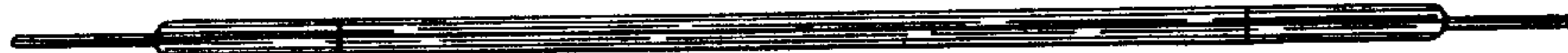
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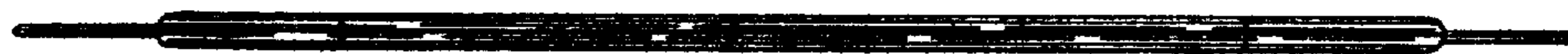
[57] CLAIM

The ornamental design for a facial mask, as shown and described.

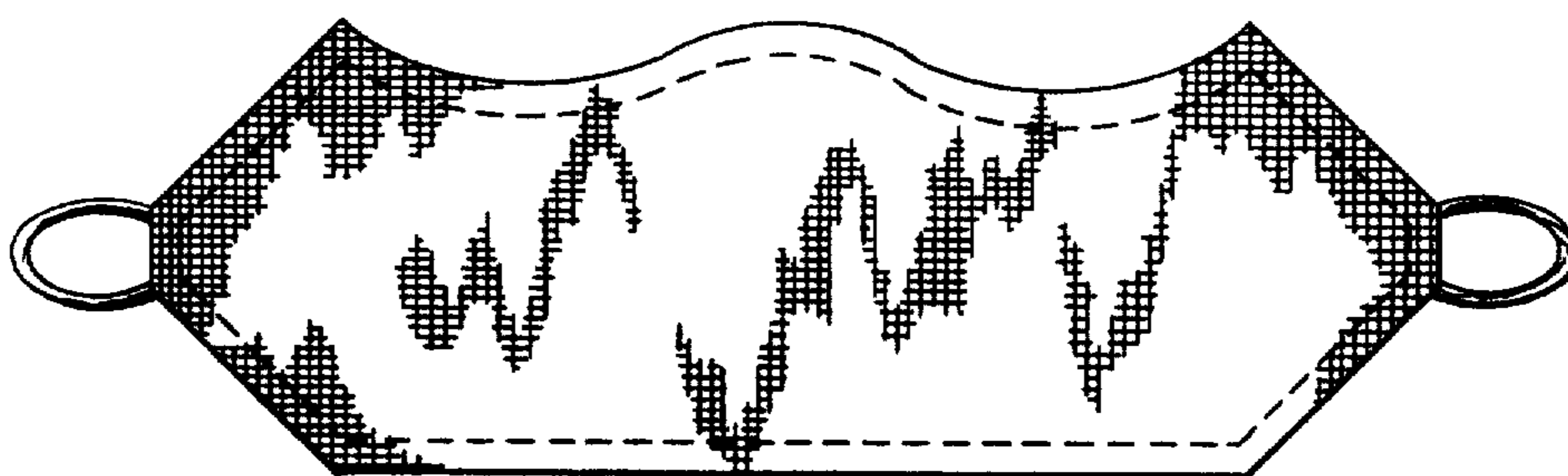
DESCRIPTION

FIG. 1 is a front elevational view of a facial mask showing my new design;  
FIG. 2 is a rear elevational view thereof;  
FIG. 3 is a top plan view thereof;  
FIG. 4 is a bottom plan view thereof;  
FIG. 5 is a left side elevational view thereof;  
FIG. 6 is a right side elevational view thereof; and  
FIG. 7 is a perspective view thereof, the broken line showing of a human profile is for illustrative purposes only.





*FIG. 3*



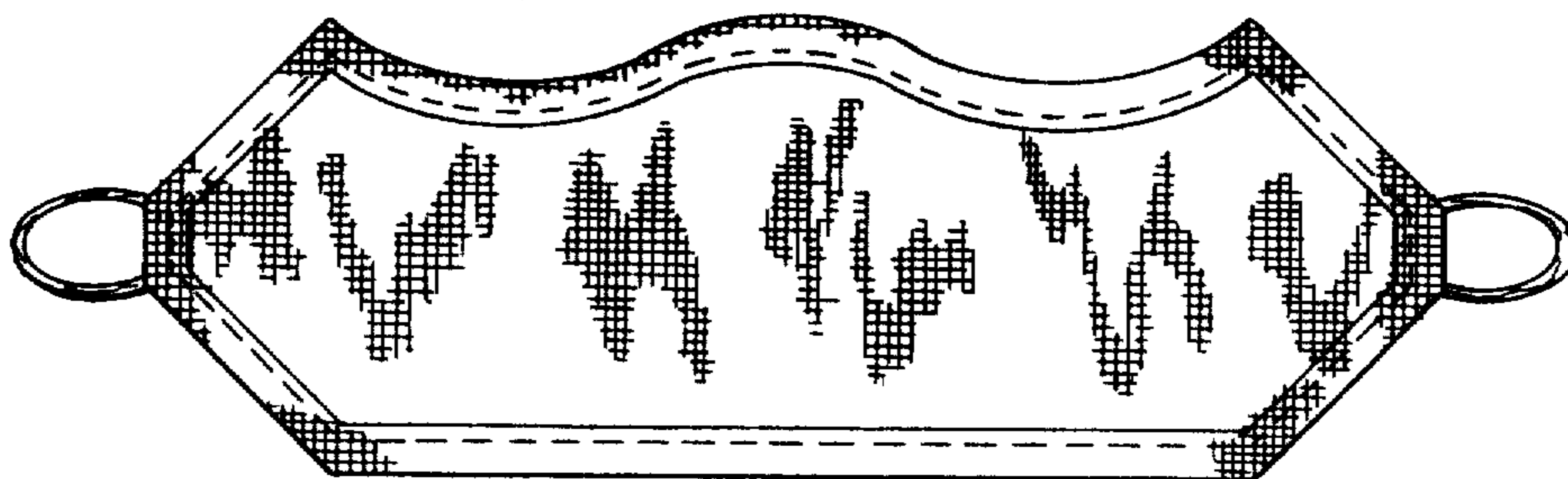
*FIG. 5*

*FIG. 1*

*FIG. 6*



*FIG. 4*



*FIG. 2*



**FIG. 7**